

 INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				ATTY DOCKET NO. 139361-2		SERIAL NO. 10/815,257	
				FILING March 31, 2004		GROUP NYA	
U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
PB	3,169,121	2/9/65	Goldberg	_____	_____		
PB	3,635,895	1/18/72	Kramer	_____	_____		
PB	4,001,184	1/4/77	Scott	_____	_____		
PB	4,081,383	3/28/78	Warburton Jr. et al.	_____	_____		
PB	4,487,896	12/11/84	Mark et al.	_____	_____		
PB	4,900,544	2/13/90	Ritter	_____	_____		
PB	4,914,150	4/3/90	Prier	_____	_____		
PB	4,943,380	7/24/90	Suguir et al.	_____	_____		
PB	6,090,907	7/18/00	Saito et al.	_____	_____		
PB	6,194,497	2/27/01	Willems et al.	_____	_____		
PB	6,407,158	2/27/01	Willems et al.	_____	_____		
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
PB	EP897950	24.02.99	Europe	_____	_____		
PB	WO01/25326	12.4.2001	PCT	_____	_____		
PB	WO01/49925	12.07.01	PCT	_____	_____		
PB	JP9279010 (abstract)	10/28/1997	Japan	_____	_____		
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
PB	Yaun et al., "Surface Enrichment of Poly(trifluorovinyl ether)s in Polystyrene Blends", Macromolecules 2000, 33, pages 4926-4931						
PB	Torstensson et al., " Monomeric Surfactants for Surface Modification of Polymers", Macromolecules 1990, 23, pages 126-132						
EXAMINER <i>P. Boykin</i>				DATE CONSIDERED <i>11/4/04</i>			
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U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

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